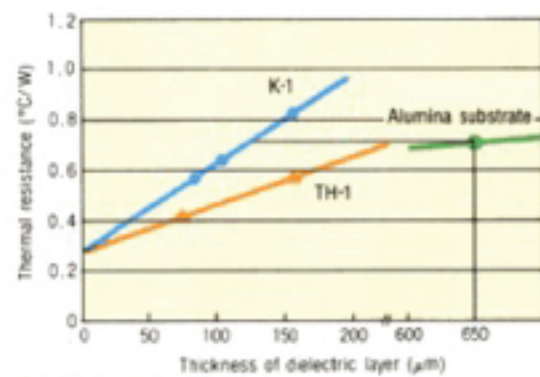


		Material	Type	Note
1	Base metal plate	Aluminum (1050)	1.0,1.5,2.0mm	
		Aluminum (5052)	3.0mm	
2	Thermally conductive dielectric layer	Epoxy resin filled with inorganic filler	Z type	Dielectric strength (AC2kV)
			Y type	Dielectric strength (AC3kV)
			X type	Dielectric strength (AC5kV)
3	1. Cu circuit	Copper foil (Ni plating / Ni-Au plating available)	35 μ m	for general circuits
			70 μ m	for large current circuits
			105 μ m	for large current circuits
	2. Cu circuit with Al pad	Al/ Cu claded foil	Al 40 μ m/Cu10 μ m	For wire-bonding (bare chip mounting)
			Al 40 μ m/Cu85 μ m	for large current circuits
4	Solder resist	Epoxy resin, etc.	5~30 μ m	

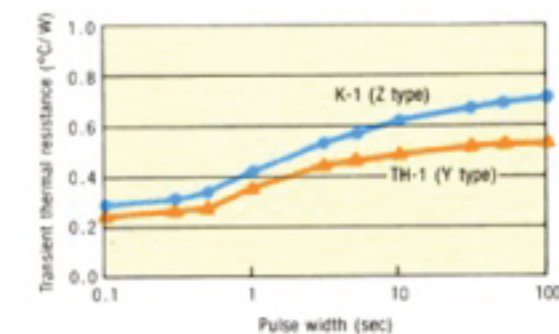
	High heat resistance, Ultra high thermal conductivity type TH-1	General purpose type K-1
Thermal conductivity (W/m K)	4.0	2.0
Volume resistivity (Ω cm) at 23°C	4.1×10^{13}	2.2×10^{13}
Coefficient of thermal expansion ($^{\circ}$ C $^{-1}$)	6.7×10^{-5}	7.8×10^{-5}
Young's modulus (N/m 2)	5.4×10^9	5.1×10^9
Poisson's ratio	0.34	0.30
Glass transition point ($^{\circ}$ C)	165	104

With DENKA's high λ -value λ -added electronic components, we accurately identify your needs and contribute to the diversification and sophistication of electronics products

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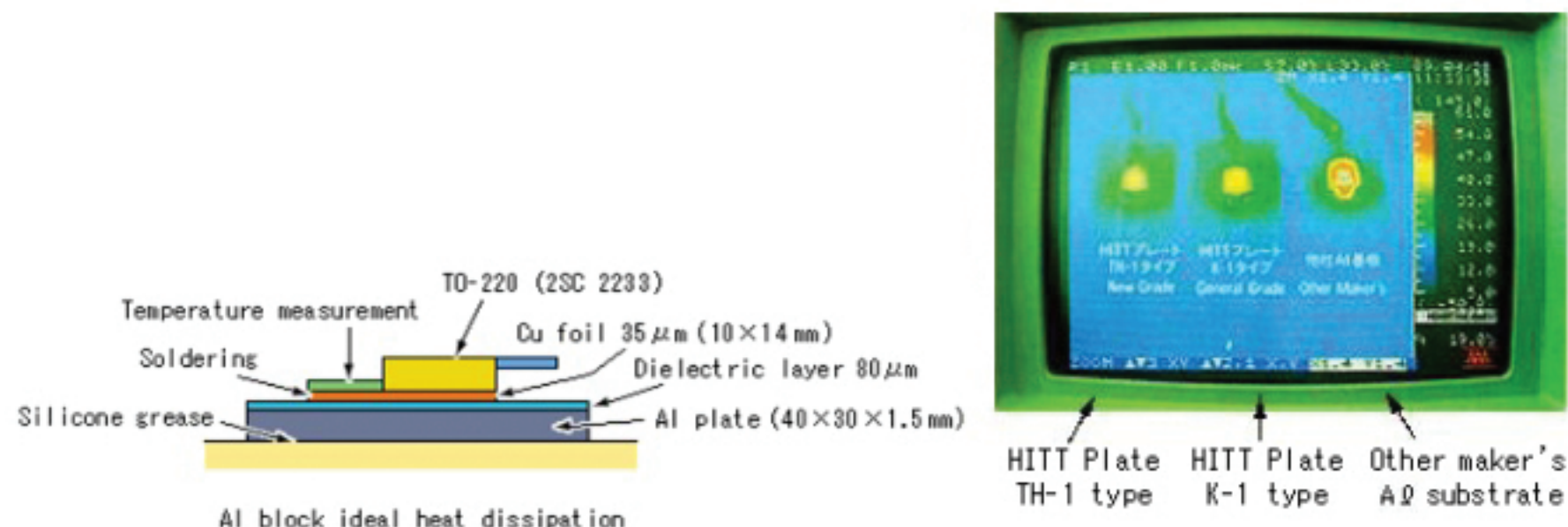


a) Thermal resistance characteristics *Simulated values are used for alumina-substrate values



b) Transient thermal resistance characteristics (20 W)

Denka Measuring Method used for the thermal conductivity of substrates



This photograph shows the thermal images with a 4A current applied for 10 seconds (T_r : TO-220). It can be seen that the temperature rise of the "DENKA HITT PLATE" is kept very small thanks to its excellent thermal conductivity.